

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

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Title of Invention	COMPOSITION FOR AN ETCHING MASK COMPRISING A SILICON-CONTAINING MATERIAL						
Application Number :	10/789319						
Confirmation Number:	9202						
First Named Applicant:	Frank Xu						
Attorney Docket Number:	P121-63-03						
Art Unit:	1712						
Examiner:	Marc S. Zimmer						
Search string:	( 6468642 or 5542978 or 5837314 or 6565776 or 6503914 or 6649272 or 6204343 or 4614667 or 3810874 or 6737489 or 6721529 or 6664306 or 6790905 or 6544594 or 6774183 or 6830819 or 6802870 or 5389696 ).pn						
<b>US Patent Documents</b>							
<b>Note: Applicant is not required to submit a paper copy of cited US Patent Documents</b>							
init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6468642	2002-10-22	Bray et al.	B1		
	2	5542978	1996-08-06	Kindt-Larsen et al.			
	3	5837314	1998-11-17	Beaton et al.			
	4	6565776	2003-05-20	Li et al.	B1		
	5	6503914	2003-01-07	Benish et al.	B1		
	6	6649272	2003-11-18	Moore et al.	B2		
	7	6204343	2001-03-20	Barucha et al.	B1		
	8	4614667	1986-09-30	Larson et al.			
	9	3810874	1974-05-14	Mitsch et al.			
	10	6737489	2004-05-18	Linert et al.	B2		
	11	6721529	2004-04-13	Chen et al.	B2		
	12	6664306	2003-12-16	Gaddam et al.	B2		
	13	6790905	2004-09-14	Fitzgerald et al.	B2		
	14	6544594	2003-04-08	Linford et al.	B2		
	15	6774183	2004-08-10	Palumbo et al.	B1		
	16	6830819	2004-12-14	Kaplan et al.	B2		
	17	6802870	2004-10-12	Chang et al.	B2		
	18	5389696	1995-02-14	Dempsey et al.			
<b>Signature</b>							

Examiner Name	Date